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Electrospray technique in fabricating perovskite-based hybrid solar cells under ambient conditions

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In this work, we utilized the electrospray technique to deposit the solidified crystal precursors on the substrate to investigate the transition processes in forming an orthorhombic methylammonium lead iodide film for fabricating perovskite planar heterojunction solar cells. The formation of solidified crystal precursors by the electrospray technique improves the de-wetting of the perovskite film on the substrate. Judicious selection of the applied voltage in the electrospray process generates crystal precursors of the appropriate dimensions. These as-electrosprayed crystals are the solid-state reactants for the halogen exchange and they form a uniformly covered film on the substrate under suitable annealing conditions. The hybrid device prepared by the electrospray technique exhibits a power conversion efficiency of 9.3%, a short-circuit current of 19.71 mA cm⁻², an open-circuit voltage of 0.87 V, and a fill factor of 0.55. The electrospray technique with the solid-state reaction mechanism proposed in this paper would be ideal for the large-area coating of a perovskite active layer, and thus has potential for use in real mass production.

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Introduction

The organic–inorganic hybrid organometal halide perovskites have drawn much attention due to their high absorption coefficients, direct band gaps, and long diffusion lengths.^{1–5} Miyasaka's group first employed methylammonium lead iodide (CH₃NH₃PbI₃, MAPbI₃) as a light sensitizer in dye-sensitized solar cells in 2009,⁶ and since then researchers have made many improvements to advance the photovoltaic parameters of perovskite-based hybrid solar cells. Snaith and co-workers used the mixed halide perovskite precursors CH₃NH₃PbI_{3–x}Cl_x deposited on “scaffold” Al₂O₃,^{7,8} and found that the perovskite layer may transport electrons without n-type TiO₂. Etgar *et al.* reported the production of a conductor-free mesoscopic perovskite/TiO₂ heterojunction solar cell.⁹ These studies indicated that the perovskite may function as a compound semiconductor to absorb the light and transport electrons/holes in the active layer. Based on this idea, various prototypes of planar architecture have been developed. An earlier work reported on the donor–acceptor contact interface for charge separation, based on the hybrid CH₃NH₃PbI₃ perovskite/fullerene (C₆₀) planar heterojunction (PHJ) with a device configuration of

organic photovoltaics (OPVs).¹⁰ Current perovskite-based solar cells with a planar architecture have achieved a highest power conversion efficiency (PCE) of approximately 20%.^{11–13}

Our previous work successfully demonstrated the fabrication of efficient hybrid solar cells by the spin-coating technique to form a perovskite layer in the PHJ configuration.¹⁰ Many recent studies have reported processes to optimize device performance.^{14–20} Some two-step approaches apply the pre-coated PbI₂ to the substrate followed by a reaction with CH₃NH₃I (MAI) vapor at 150 °C in N₂ atmosphere,¹⁴ or an inter-diffusion reaction between MAI with PbI₂ in a MAI/PbI₂ double layer configuration^{15,16} to form the perovskite layer. Other approaches apply the mixed solvent to enhance the morphology of perovskite film^{17,18} or introduce the additives (1,8-diiodooctane, polyvinylpyrrolidone, NH₄Cl or HI) into the precursor solution to improve the crystallinity while casting the perovskite layer.^{19,20} However, during the film forming process of the perovskite layer, the de-wetting of the film on the substrate causes supersaturation of the solution at different times and positions. In addition, the wet-coating approach may not be a suitable process to prepare the perovskite layer on a large-area substrate, which is needed for practical applications. Accordingly, we are interested in developing an approach to deposit solidified crystal precursors on the substrate at an early reaction stage and then to convert the solid precursors into a perovskite layer through a solid-state reaction at an elevated temperature, as this process could be suitable for large-area coating.

Solid state reactions have been applied to prepare light-absorbing layers, such as Cu₂ZnSnS₄ (CZTS)²¹ and CuInSe₂ (CIS),²² under non-vacuum conditions. We fabricated a CuInSe₂

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thin film *via* a low temperature solid state reaction from the as-deposited individual binary precursor CuSe and InSe powders.²³ It should be noted that nanocrystals are more chemically active than bulk materials in the solid-state reaction to convert the reactant into the product.²⁴ The electrospray technique produces size-selected and highly dispersive nanocrystals,^{25–27} such as nanostructure oxide ceramic powders,^{28–30} for use in light emitting diodes,³¹ fuel cells^{32,33} and solar cells.^{34,35} In other words, the electrospray method could be a suitable and easy process to deposit small solidified crystals of the appropriate dimensions for halide exchange, thus enabling phase transformation in the solid-state reaction to prepare the perovskite active layer on the substrate.

In this paper, we apply an electrospray technique to make the solidified crystals that are then used as precursors. Later, through solid-state diffusion induced by heat treatment, the solid precursors convert to an orthorhombic $\text{CH}_3\text{NH}_3\text{PbI}_3$ layer for the fabrication of hybrid perovskite/ C_{60} PHJ solar cells. We adjust the applied voltages in the electrospray process to modulate the dispersion density of the solidified crystals, which is the key parameter to determining the surface coverage of the precursors for the subsequent solid reaction. The orthorhombic $\text{CH}_3\text{NH}_3\text{PbI}_3$ perovskite film exhibits a suitable morphology for use in device fabrication. The resulting cell presents decent photovoltaic parameters, with an open-circuit voltage (V_{OC}) of 0.87 V, a short-circuit current (J_{SC}) of 19.71 mA cm^{-2} , and a fill factor (FF) of 0.55, corresponding to a PCE of 9.3%. The electrospray technique with the solid reaction mechanism proposed in this paper would be ideal for the large-area coating of a perovskite layer for real mass production.

Experimental

Material and sample preparation

Methyl ammonium iodide ($\text{CH}_3\text{NH}_3\text{I}$) was synthesized by reacting 14 mL of methylamine (CH_3NH_2 , 40 wt% in methanol, Alfa Aesar) and 15 mL of hydroiodic acid (HI, 57 wt% in water, Showa) in a 100 mL round-bottom flask at 0°C under nitrogen atmosphere for 2 h with stirring. After the reaction, the solvent of the solution was evaporated using a rotary evaporator and the solvents were carefully removed at 50°C . A white colored powder, $\text{CH}_3\text{NH}_3\text{I}$, was formed after the reaction. The precipitate was washed with diethyl ether (99.7%, Sigma-Aldrich) three times and dried at 60°C in a vacuum oven overnight. Precursor solution $\text{CH}_3\text{NH}_3\text{PbI}_{3-x}\text{Cl}_x$ was synthesized by mixing $\text{CH}_3\text{NH}_3\text{I}$ and lead chloride (PbCl_2) (98%, anhydrous, Merck) in a 3 : 1 molar ratio with a total concentration of 100 mg mL^{-1} dissolved in *N,N*-dimethylformamide (DMF) ($\geq 99.8\%$, Fisher Scientific) at 60°C with stirring for 12 h.

Device fabrication

Prior to device fabrication, the pre-patterned glass/indium-tin-oxide (ITO) ($15 \Omega \square^{-1}$, RITEK Corp.) was sequentially cleaned by ultrasonic treatment in detergent, de-ionized water, acetone and isopropyl alcohol. For the cell fabricated on a glass/ITO/poly(3,4-ethylenedioxythiophene) poly(styrene-sulfonate) (PEDOT:PSS)

substrate, the PEDOT:PSS (Baytron PVP Al 4083, filtered with $0.45 \mu\text{m}$ PVDF filter) was spin-coated onto the ultraviolet ozone treated glass/ITO substrate at 4000 rpm for 60 s, and then annealed in air at 150°C for 25 minutes. The perovskite precursor was then deposited on the glass/ITO/PEDOT:PSS under ambient conditions by electrospray deposition. The electrospray setup is depicted in Fig. 1(a), and consisted of a syringe and needle (internal diameter 0.21 mm), a syringe pump (KdScientific, Model 200), a high positive voltage power supply (You-Shang Technical Corp.), and an aluminium foil as the plate ground electrode. At the electrospray deposition, a syringe attached to a syringe pump was filled with the as-prepared $\text{CH}_3\text{NH}_3\text{PbI}_{3-x}\text{Cl}_x$ solution. The flow rate was set at 0.5 mL h^{-1} . The electrospray started by applying a high positive voltage of 20 kV at the electrode (nozzle head). The distance between the nozzle head and the ground electrode (aluminium foil) was 9 cm. The deposition time was 80 s, and the substrate was held at 70°C by a hotplate. The perovskite films were then annealed at 90, 110, 130°C for 60 minutes under ambient conditions. Afterward, the samples were transferred to a thermal evaporator to deposit the fullerene (C_{60}) (30 nm) ($>99.0\%$, Solenne), bathocuproine (BCP) (10 nm) (Sigma-Aldrich), and Al electrode (100 nm) in sequence under a vacuum of 6×10^{-6} Torr. The active area of the device was 0.06 cm^2 .

Characterization

The device characteristics, the current density–voltage (J – V) curves, were measured in a nitrogen-filled glove box using a Keithley 2400 SourceMeter under standard 1 sun AM 1.5G simulated irradiation (100 mW cm^{-2}) from a Newport 91160A 300W Solar Simulator (Class A). The light intensity for the illumination can be tuned by placing a neutral density filter in front of the device during the measurement. The scan rate was 0.1 V s^{-1} . The simulated solar irradiance was corrected by a Schott visible-color glass-filtered (KG5 color filter) Si diode

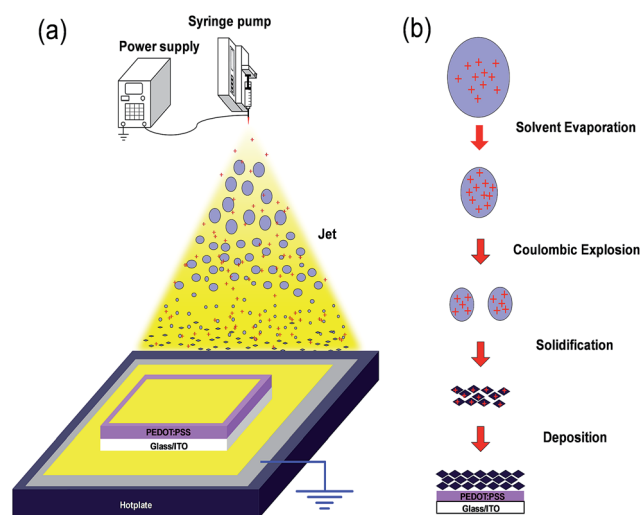


Fig. 1 (a) A schematic of the setup we used to prepare the solidified crystals on a glass/ITO/PEDOT:PSS substrate by the electrospray technique, and (b) a schematic of the formation of solidified crystals.



(Hamamatsu S1133). The incident photon to electron conversion efficiency (IPCE) spectra were measured by a 300 W xenon light source (Oriel), Oriel Cornerstone 130 1/8 m monochromator, Keithley 2400 sourcemeter, a chopper (SR540, Stanford Research System Inc.) and a Lock-in amplifier (SR510, Stanford Research System Inc.). The crystallographic properties of perovskite on the glass/ITO/PEDOT:PSS substrate were characterized by X-ray diffraction (XRD) measurements (Simatsu, XRD6000, Japan), as recorded using a Cu K α ($\lambda = 0.15418$ nm) radiation source that was operated at 40 kV and 100 mA. The X-ray diffractogram was obtained at a scan rate of $0.03^\circ \text{ s}^{-1}$ for 2θ values between 10° and 60° . The surface coverage of the perovskite images was obtained using an optical microscope (Olympus BX51M, Japan) and analyzed using the ImageJ software package. The particle images were obtained using a scanning electron microscopy (SEM) system (Hitachi, 4200A, Japan) operating at 10 kV.

Results and discussion

The solidified crystals were prepared on a glass/indium-tin-oxide (ITO)/poly(3,4-ethylenedioxythiophene) poly(styrene-sulfonate) (PEDOT:PSS) substrate by the electrospray technique described above. Since the electrostatic force overcomes the surface tension of the spray solution at a sufficiently high electric bias, the solution arriving at the nozzle head directly nebulizes as a jet of liquid droplets. Eventually, these droplets are accelerated by the electric field toward the grounded plate and deposited on the glass/ITO/PEDOT:PSS substrate.

Fig. 1(b) shows a schematic of the formation of solidified crystals on the glass/ITO/PEDOT:PSS substrate. There are four steps that occur as the droplets are accelerated toward the grounded plate in the electrospray process: solvent evaporation, coulombic explosion, solidification and deposition. Liquid droplets in a jet carry charges when they leave the nozzle head. The droplets are dispersed due to the repulsive force of the charges on the droplets. "Solvent evaporation" then occurs and raises the surface charge density due to a decrease in the droplet volume and the surface area. As electrostatic force overcomes the surface tension to reach the limit of the charge-mass ratio (the Rayleigh limit³⁶), the droplets further disrupt into smaller droplets (satellite droplets), a process which is termed "Coulombic explosions". The droplets continuously go through the above "solvent evaporation" and "Coulombic explosions" processes several times while traveling between the nozzle head and substrate. Finally, the evaporation of solvent precipitates the solutes from the tiny droplets and the solidified solutes are deposited on the substrate. The deposition of the solidified crystals or powders is correlated with the tiny droplet sizes, which can be modulated by the applied voltage on the nozzle head and the distance from the substrate. Accordingly, the size-selected and highly dispersive nano solids can be deposited on the glass/ITO/PEDOT:PSS substrate by the electrospray process.

Fig. 2 shows the optical microscope (OM) images of the films on glass/ITO/PEDOT:PSS substrates as deposited by different applied voltages. The concentration of the electrospray solution, deposition time, and the substrate temperature were all

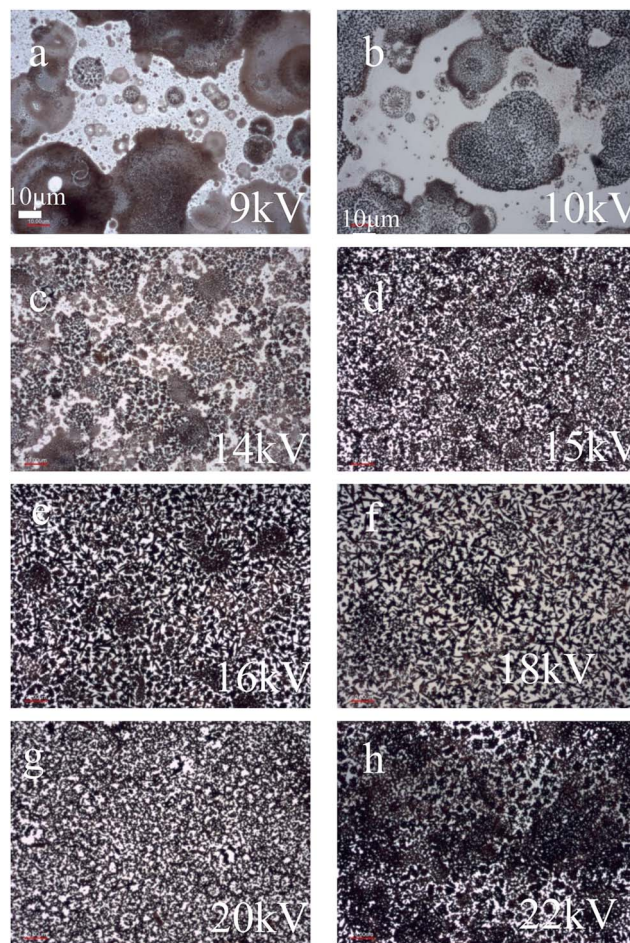


Fig. 2 OM images of the films on glass/ITO/PEDOT:PSS substrates as deposited by different applied voltages: (a) 9, (b) 10, (c) 14, (d) 15, (e) 16, (f) 18, (g) 20, and (h) 22 kV.

identical and set at 100 mg L^{-1} , 80 s, and 70°C , respectively. As illustrated by the OM images in Fig. 2, the surface of the substrate for the samples deposited at the biased voltages between 9 to 14 kV is composed of many large patterns. Presumably, the electrostatic force at these biases did not reach the Rayleigh limit on the droplets to induce sequential coulombic explosions, so the droplet size did not decrease. The large droplets were thus directly deposited on the substrate, resulting in a very rough surface morphology of the films on the substrate. Further increasing the applied voltages to a magnitude of 15–22 kV markedly improved the coverage of the solid films on the substrates, as depicted in Fig. 2. It should be noted that the sample prepared using a 20 kV applied voltage is densely covered with a solid film, and this would thus be the optimal condition in this study. However, the high voltage, 22 kV, has a negative effect on the deposition of the film. As shown in Fig. 2, there are many dark patterns on the OM image of the sample deposited at 22 kV. At the high applied voltage the droplets easily explode at an early stage due to the fact that the Coulomb force is greater than the surface tension in the droplet,³⁷ which can lead to non-uniform deposition of the solids on the substrate.



Fig. 3 shows the X-ray diffraction (XRD) patterns for the as-deposited film prepared at 20 kV on glass/ITO/PEDOT:PSS substrates and the films annealed at 110 °C for 0, 20 and 60 minutes. As shown in Fig. 3, the peaks at 14.1°, 28.4°, 43.2°, and 58.9° are assigned to the (110), (220), (330), and (440) planes, respectively, for the orthorhombic crystal structure of $\text{CH}_3\text{NH}_3\text{PbI}_3$.³⁸ For the as-deposited film without 110 °C annealing, the peaks at 12° and 16.8° (marked with “*” sign) are assigned to XRD patterns by a Pb-complex^{39,40} composed of Pb halide and the organic species. We observe a small shift in preferred orientation (220) peaks toward the higher diffraction angles with the *d*-spacing changes in Fig. 3(b), indicating lattice distortion by the substitution of the Cl with I as the atom radius of Cl (0.167 nm) atoms is much smaller than I (0.206 nm). The excess Cl ions in the solid film react with $\text{CH}_3\text{NH}_3\text{PbI}_3$ crystallite and form a $\text{CH}_3\text{NH}_3\text{PbI}_3\text{:Cl}$ intermediate at early reaction stage. Through the thermal treatment to anneal the film at 110 °C for 20 minutes, the magnitudes of the (100) and (200) peaks increase markedly and the peaks at 12° and 16.8°, as shown in the XRD pattern of the as-deposited sample disappear, indicating the transformation of precursors to form orthorhombic $\text{CH}_3\text{NH}_3\text{PbI}_3$. The prolonged thermal treatment (110 °C for 60 minutes) further increases the relative magnitude of XRD

patterns, with a full width at half maximum (FWHM) of 0.22°, suggesting the relatively high crystallinity of perovskite film, and the peak at the 15.6° diffraction angle assigned to MAPbCl_3 disappears, as shown in the inset of Fig. 3(b). This observation for the thermal treatment of orthorhombic $\text{CH}_3\text{NH}_3\text{PbI}_3$ perovskite herein agrees with the results of previous research.⁴¹ In this study, annealing the film prepared by electrospraying at 110 °C for 60 minutes can form an orthorhombic $\text{CH}_3\text{NH}_3\text{PbI}_3$ film on the glass/ITO/PEDOT:PSS substrate with the appropriate crystal phases for device fabrication.

It should also be noted that surface morphology of the perovskite films produced in this study is correlated with the annealing temperature. Fig. 4 shows scanning electron microscopy (SEM) images with a magnification of 5k× for perovskite films on glass/ITP/PEDOT:PSS substrates annealed at 70, 90, 110, and 130 °C for 60 minutes. For the sample annealed at 70 °C, as presented in Fig. 4(a), the SEM image shows that the surface morphology is composed of many solid particles with dimensions of around 1.5–2.0 μm. This indicates that the temperature of 70 °C is too low to initiate the interdiffusion process of the solid to form a continuous film on the substrate. Fig. 4(b) presents an SEM image of the sample annealed at 90 °C for 60 minutes. Under this annealing condition, we observe the growth of perovskite film on the substrate as induced by the diffusion of the solid at the elevated temperature, but there are still many voids with dimensions larger than a few μm. The number and density of voids should thus be reduced for better coverage of the film on the substrate. Further increasing the temperature to 110 °C markedly improves the morphology of the perovskite film and decreases the surface roughness, as illustrated in Fig. 4(c). This result is correlated with XRD measurement in Fig. 3, which shows that the film exhibits a good crystal structure when annealed at 110 °C for 60 minutes. However, annealing the sample at 130 °C dramatically changes the surface morphology. As shown in Fig. 4(d), the SEM image reveals many large crystals on the substrate. The film is discrete, with many big voids between grains, and thus is not applicable as an active layer for the fabrication of good photovoltaic cells.

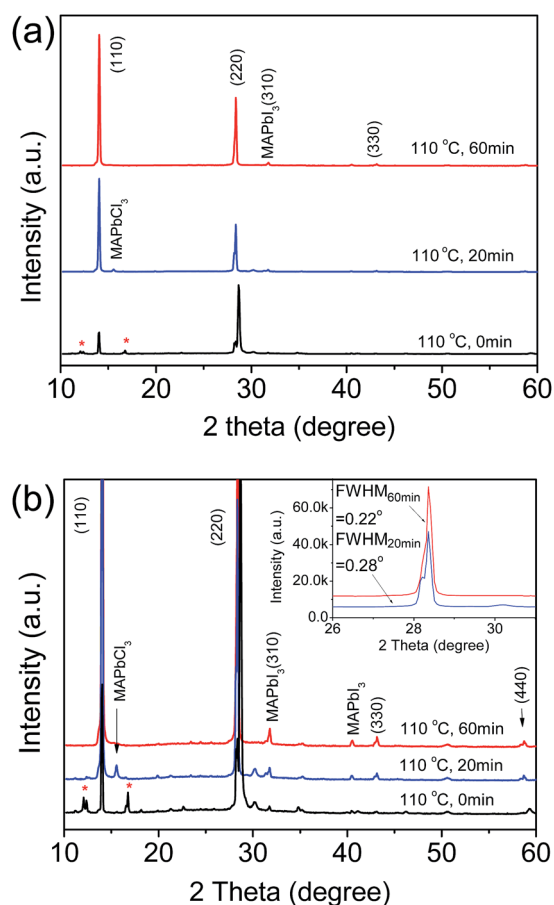


Fig. 3 XRD patterns for the as-deposited film prepared at 20 kV on glass/ITO/PEDOT:PSS substrates and the films annealed at 110 °C for 0, 20 and 60 minutes.

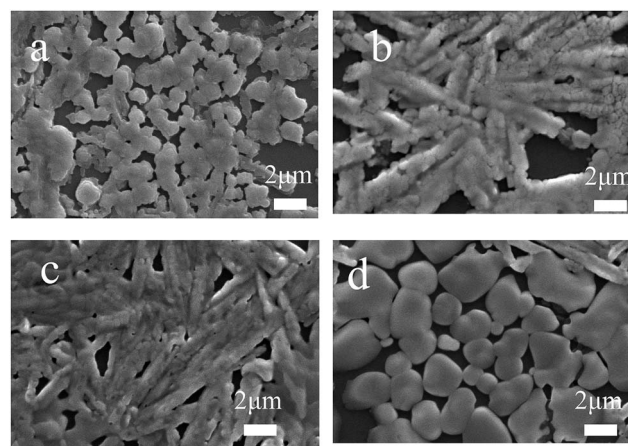


Fig. 4 SEM images of the perovskite films on glass/ITP/PEDOT:PSS substrates annealed at (a) 70, (b) 90, (c) 110, and (d) 130 °C for 60 minutes.



Fig. 5(a) presents the schematic device structure and the current density–voltage (J – V) curves with forward (hollow icons) and reverse scans (solid icons) of hybrid perovskite solar cells of glass/ITO/PEDOT:PSS/orthorhombic $\text{CH}_3\text{NH}_3\text{PbI}_3$ perovskite/ C_{60} /bathocuproine (BCP)/Al configuration under the standard 1 sun AM 1.5G simulated solar irradiation. As plotted in Fig. 5, the hybrid cell made of a $\text{CH}_3\text{NH}_3\text{PbI}_{3-x}\text{Cl}_x$ active layer by the electro spray method reported in this work exhibits a V_{OC} of 0.87 V, a J_{SC} of 19.71 mA cm^{-2} , and an FF of 0.55, corresponding to a PCE of 9.3%. These photovoltaic parameters are comparable to those of a hybrid cell with a $\text{CH}_3\text{NH}_3\text{PbI}_{3-x}\text{Cl}_x$ active layer prepared by the conventional spin-coating process, which exhibits a V_{OC} of 0.94 V, a J_{SC} of 17.74 mA cm^{-2} , and an FF of 0.6, corresponding to a PCE of 10%. Fig. 5(b) shows the incident

photon to electron conversion efficiency (IPCE) spectrum of the cell fabricated by electrospraying having a peak IPCE above 80% at approximately 420–500 nm. The photocurrent integrated from the overlap of the IPCE spectrum with the AM 1.5G solar irradiation gives a current density of 18.35 mA cm^{-2} , in which the integrated photocurrent is correlated with a magnitude of J_{SC} , as depicted in Fig. 5(a). Fig. 6 shows the cross-sectional image of the hybrid device in this study. We observe a compact perovskite active layer with a thickness of approximately 380–400 nm. The electrospray technique developed herein is thus a suitable approach to deposit perovskite materials for fabricating hybrid solar cells. For the devices made of an orthorhombic $\text{CH}_3\text{NH}_3\text{PbI}_3$ active layer annealed at 90 °C and 130 °C instead of 110 °C for 60 minutes, we observe the photovoltaic parameters of a V_{OC} of 0.81 V, a J_{SC} of 15.23 mA cm^{-2} , and an FF of 0.44, corresponding to a PCE of 5.4% for the 90 °C device, and a V_{OC} of 0.85 V, a J_{SC} of 13.57 mA cm^{-2} , and an FF of 0.30, corresponding to a PCE of 3.5% for the 130 °C device. The relatively low device performance is due to the non-uniform coverage or incomplete reaction of perovskite film on the substrate. As seen in the SEM image in Fig. 4(d), the voids between grain boundaries cause electric shunting between the electrodes, markedly reducing the FF, J_{SC} , and PCE of the solar cells. In addition, the J – V curve for the hybrid cell made of a $\text{CH}_3\text{NH}_3\text{PbI}_3$ active layer prepared by electrospraying $\text{CH}_3\text{NH}_3\text{I}$ and PbI_2 (molar ratio of 1 : 1) in the DMF solution is plotted in Fig. 5 for comparison. The device exhibits a V_{OC} of 0.63 V, a J_{SC} of 5.77 mA cm^{-2} , and an FF of 0.25, corresponding to a PCE of 0.9%. The low device performance is attributed to the too fast formation of $\text{CH}_3\text{NH}_3\text{PbI}_3$ crystals during the electrospray process. $\text{CH}_3\text{NH}_3\text{I}$ instantly reacts with PbI_2 solids to form $\text{CH}_3\text{NH}_3\text{PbI}_3$ perovskite, and thus the film does not uniformly cover the substrate, and the thermal treatment also did not improve the morphology of the $\text{CH}_3\text{NH}_3\text{PbI}_3$ film. On the other hand, the formation rate of $\text{CH}_3\text{NH}_3\text{PbI}_{3-x}\text{Cl}_x$ is relatively slow compared to that of $\text{CH}_3\text{NH}_3\text{PbI}_3$,⁴² thus causing better coverage of the film on the glass/ITO/PEDOT:PSS substrate. The surface morphology of the $\text{CH}_3\text{NH}_3\text{PbI}_3$ film is too rough, as can be seen by the naked eye, and is not able to make a uniform film for fabricating decent cells. Accordingly, the morphology of the perovskite film prepared by

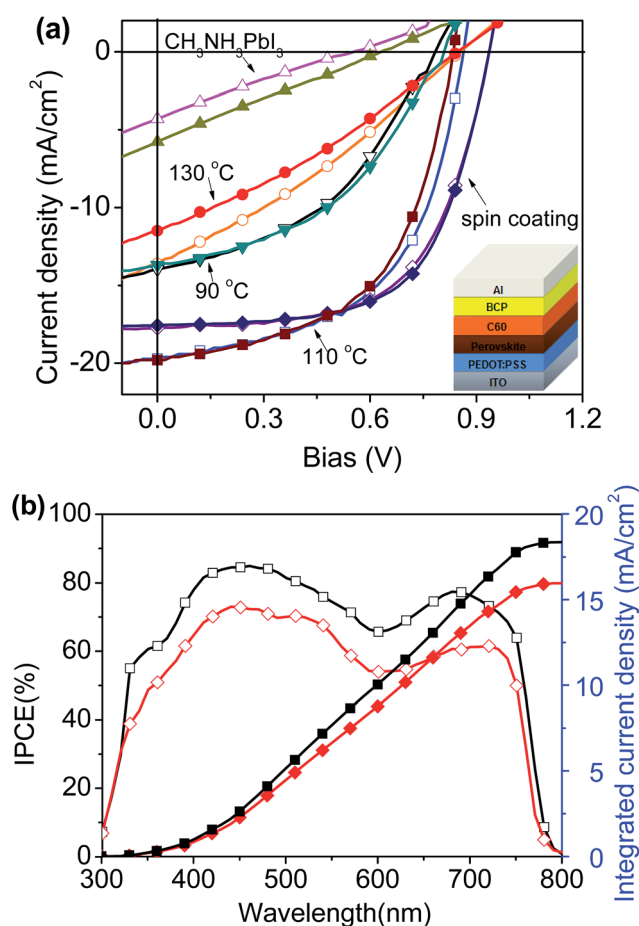


Fig. 5 (a) The schematic device structure and the current J – V curves with forward (hollow icons) and reverse scans (solid icons) for hybrid perovskite solar cells of glass/ITO/PEDOT:PSS/orthorhombic $\text{CH}_3\text{NH}_3\text{PbI}_3$ perovskite/ C_{60} /BCP/Al fabricated by electrospraying and then annealed at 90 °C (▽/▼), 110 °C (□/■), and 130 °C (○/●) for 60 minutes and fabricated by conventional spin coating (◇/◆), and the glass/ITO/PEDOT:PSS/ $\text{CH}_3\text{NH}_3\text{PbI}_3$ perovskite/ C_{60} /BCP/Al (Δ/\blacktriangle) configuration under the standard 1 sun AM 1.5G simulated solar irradiation. (b) The IPCE spectra and the integrated photocurrent calculated under AM 1.5G solar irradiation of the cells of glass/ITO/PEDOT:PSS/orthorhombic $\text{CH}_3\text{NH}_3\text{PbI}_3$ perovskite/ C_{60} /BCP/Al fabricated by electrospraying then annealed at 110 °C for 60 minutes (□/■) and fabricated by conventional spin coating (◇/◆).

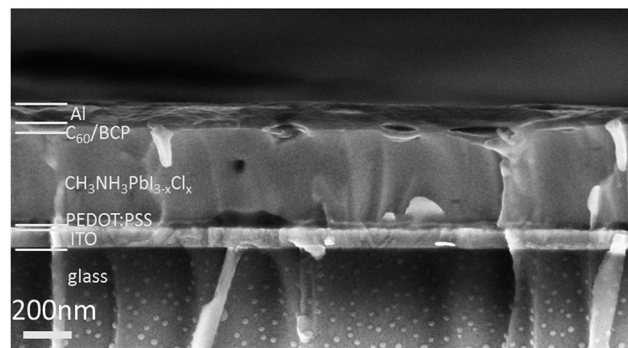


Fig. 6 Cross-sectional image of the hybrid device produced in this study with a glass/ITO/PEDOT:PSS/orthorhombic $\text{CH}_3\text{NH}_3\text{PbI}_3$ perovskite/ C_{60} /BCP/Al configuration.



electrospraying in our current study is still the key component to determining the photovoltaic parameters of the cells, which can be modulated by the precise control of the applied voltage, solution concentration, annealing temperature and time, as well as other parameters. Note that the stability of the materials and solar cell performance are important issues that have been commonly shown in perovskites made by spin-coating and vacuum evaporation methods. The stability of the unencapsulated perovskite solar cell devices made by our electrospray method was further tested during exposure to 70% RH at room temperature for about 200 hours. The device PCE was reduced to approximately 50% of the initial values due to significant decay of the J_{SC} and FF. Although the device fabrication of perovskite solar cells can be realized in ambient conditions for real mass production, the long-term stability of the photovoltaic performance should be further improved through encapsulation or interface engineering in the future.

Conclusions

In conclusion, in this work we successfully demonstrated an electrospray technique to deposit solidified crystal precursors on the substrate and convert the solids to form an orthorhombic $\text{CH}_3\text{NH}_3\text{PbI}_3$ active layer for fabricating perovskite-based hybrid solar cells. Depositing the solids by electrospraying improves the de-wetting of the layer when using the wet-coating process on the substrate. The applied voltages between the nozzle head and the ground electrode in the electrospray process modulate the uniformity and initial morphology of the deposited film. Thermal annealing at an elevated temperature improves the crystallinity and coverage of the perovskite film on the substrate. A hybrid cell made of the active layer produced by the electrospray process exhibits a V_{OC} of 0.87 V, a J_{SC} of 19.71 mA cm^{-2} , and an FF of 0.55, corresponding to a PCE of 9.3%, which is comparable to the performance of a cell prepared by the conventional spin-coating process. The results indicate that the electrospray technique developed in this work would be ideal to achieve large-area coating of a perovskite active layer with the potential for real mass production. We understand that the morphology of the deposited film is still the key component to determining the photovoltaic parameters of the resulting cells. Intensive work to further advance the device performance is currently in progress.

Acknowledgements

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